

TI Skin preparations containing surfactants or moisturizers from Pseudomonas species
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 SO Jpn. Kokai Tokkyo Koho, 6 pp.
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 DT Patent
 LA Japanese
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 ICI C12P001-04, C12R001-38
 CC 62-4 (Essential Oils and Cosmetics)
 Section cross-reference(s): 16
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PI	JP 08208427	A2	19960813	JP 1995-17635	19950206 <--
AB	Skin preps. contain surfactants or moisturizers from Pseudomonas sp. or their exts. <i>P. putida</i> was cultured in a medium contg. glycine betaine, yeast ext., pyruvic acid, and salts at 27.degree. for 48 h to produce surface-active substance, which (3.0 wt.%) was mixed with dipropylene glycol 2.0, glycerin 3.0, H ₂ O 34.0, cetanol 8.0, jojoba oil 5.0, squalane 27.5, silicone 15.0 wt.%, perfume, and antiseptic to prep. a cream. The cream gave luster, moisture, and smoothness to the skin.				
ST	skin prepn surfactant moisturizer Pseudomonas				
IT	Fermentation Pseudomonas Pseudomonas putida Surfactants (skin preps. contg. surfactants or moisturizers from Pseudomonas sp.)				
IT	Cosmetics (conditioners, skin preps. contg. surfactants or moisturizers from Pseudomonas sp.)				

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